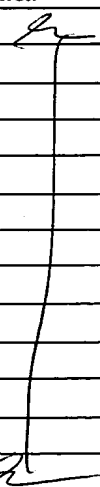


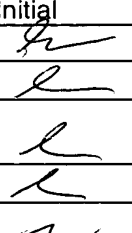
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| <b>Form 1449 (Modified)</b><br><br><b>Information Disclosure Statement By Applicant</b><br><br>(Use Several Sheets if Necessary) | Attorney Docket No: U.S.<br>LAM2P220C 09/747,844<br>Applicant: Kistler et al.<br>Filing Date: December 21, 2000<br>Group: 3723 |
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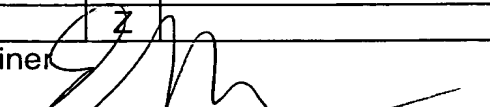
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Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.